

What Is Claimed Is:

Sub A 1. A liquid crystal display device comprising:
a first electrode on a first substrate having a plurality of slit patterns;
a second electrode on a second substrate;
a liquid crystal layer between the first and second substrates, the liquid crystal layer having different alignment directions by each slit pattern; and
at least one light-shielding layer below the first electrode.

Sub C' 2. The device as claimed in claim 1, wherein the light-shielding layer is located below a middle portion of the first electrode.

3. The device as claimed in claim 1, wherein the light-shielding layer is located below each slit pattern.

ab A5 4. The device as claimed in claim 1, wherein the light-shielding layer is located below both the first electrode and the slit patterns.

Sub C1 5. The device as claimed in claim 1, wherein the first electrode includes a transparent conductive material.

6. The device as claimed in claim 1, wherein the second electrode includes a transparent conductive material.

7. The device as claimed in claim 1, further comprising an insulating film on an entire surface of the first substrate.

ab AB 8. A method of fabricating a liquid crystal display device on first and second substrates, comprising:

forming at least one light-shielding layer on the first substrate;

forming a first electrode having a plurality of slit patterns over the light-shielding layer including the first substrate;

forming a second electrode on the second substrate;
assembling the first and second substrates; and
forming a liquid crystal layer having different
alignment directions by each slit pattern between the first and
second substrates.

9. The method as claimed in claim 8, wherein the light-shielding layer is formed below a middle portion of the first electrode.

10. The method as claimed in claim 8, wherein the light-shielding layer is formed below each slit pattern.

11. The method as claimed in claim 8, wherein the light-shielding layer is formed below middle portions of both the first electrode and the slit patterns.

12. The method as claimed in claim 8, wherein the first electrode includes a transparent conductive material.

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13. The method as claimed in claim 8, wherein the second electrode includes a transparent conductive material.

14. The method as claimed in claim 8, further comprising forming an insulating film on an entire surface of the first substrate and the light-shielding layer.

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